

Docket No.: IPA-007

10/533302

JC17 Rec'd PCT/PTO 29 APR 2005 PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Akira NAKASHIMA et al.

U.S. Patent Application No.: -----

Filed: *herewith*

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Confirmation No.

Group Art Unit: -----

For: METHOD OF FORMING AMORPHOUS SILICA-BASED COATING FILM WITH  
LOW DIELECTRIC CONSTANT AND THUS OBTAINED SILICA-BASED  
COATING FILM

**PRELIMINARY AMENDMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

Preliminary to examination of the above-referenced application, please amend the application as follows:

**AMENDMENTS TO THE SPECIFICATION**

**AMENDMENTS TO THE CLAIMS:**

**REMARKS**